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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/581,878	09/11/2000	Tadahiro Ohmi	FUK-71	7595
22855 7	590 04/22/2003			
RANDALL J. KNUTH P.C.			EXAMINER	
	ELLHORN ROAD YNE, IN 46815-4631		ALEJANDRO MULERO, LUZ L	
			ART UNIT	PAPER NUMBER
			1763	
			DATE MAILED: 04/22/2003	

Please find below and/or attached an Office communication concerning this application or proceeding.

PTO-90C (Rev. 07-01)

		G.					
	Application No.	Applicant(s)					
	09/581,878	OHMI ET AL.					
Office Action Summary	Examiner	Art Unit					
	Luz L. Alejandro	1763					
The MAILING DATE of this communication a		orrespondence address					
Period for Reply							
A SHORTENED STATUTORY PERIOD FOR REP THE MAILING DATE OF THIS COMMUNICATION - Extensions of time may be available under the provisions of 37 CFR of after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a recommendation of the period for reply specified above, the maximum statutory perion failure to reply within the set or extended period for reply will, by statused and patent term adjustment. See 37 CFR 1.704(b). Status	I. 1.136(a). In no event, however, may a reply be timely within the statutory minimum of thirty (30) days dealth apply and will expire SIX (6) MONTHS from the cause the application to become ABANDONE	nely filed s will be considered timely. the mailing date of this communication. D (35 U.S.C. § 133).					
1) Responsive to communication(s) filed on 07	7 October 2002 and 06 January 200	D3 .					
	This action is non-final.						
3) Since this application is in condition for allow	wance except for formal matters, pr	osecution as to the merits is					
closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213. Disposition of Claims							
4)⊠ Claim(s) <u>1-11</u> is/are pending in the application.							
4a) Of the above claim(s) is/are withdr	awn from consideration.						
5) Claim(s) is/are allowed.							
6)⊠ Claim(s) <u>1-11</u> is/are rejected.							
7) Claim(s) is/are objected to.							
8) Claim(s) are subject to restriction and/or election requirement.							
Application Papers							
9)☐ The specification is objected to by the Examiner.							
10)☐ The drawing(s) filed on is/are: a)☐ accepted or b)☐ objected to by the Examiner.							
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).							
11)☐ The proposed drawing correction filed on is: a)☐ approved b)☐ disapproved by the Examiner.							
If approved, corrected drawings are required in reply to this Office action.							
12)☐ The oath or declaration is objected to by the Examiner.							
Priority under 35 U.S.C. §§ 119 and 120							
13) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).							
a)☐ All b)☐ Some * c)☐ None of:							
 Certified copies of the priority documents have been received. 							
2. Certified copies of the priority documents have been received in Application No							
3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).							
* See the attached detailed Office action for a list of the certified copies not received.							
14) Acknowledgment is made of a claim for domestic priority under 35 U.S.C. § 119(e) (to a provisional application)a) ☐ The translation of the foreign language provisional application has been received.							
15) Acknowledgment is made of a claim for domes	ovisional application has been rece tic priority under 35 U.S.C. §§ 120	eived. and/or 121.					
Attachment(s)	_						
1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449) Paper No(s)	5) Notice of Informal P.	(PTO-413) Paper No(s) atent Application (PTO-152)					

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DETAILED ACTION

Claim Objections

Claim 3 and 8 are objected to under 37 CFR 1.75(c), as being of improper dependent form for failing to further limit the subject matter of a previous claim. Applicant is required to cancel the claim(s), or amend the claim(s) to place the claim(s) in proper dependent form, or rewrite the claim(s) in independent form. Both claims 3 and 8 contain the limitation "wherein said vacuum vessel can be divided into a part including said processing chamber and a part having said substrate transport mechanism". Both of these limitations are in independent claims 1 and 2, as amended (see claim 1, lines 7-20 and claim 2, lines 7-22).

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to

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consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).

Claims 1-4, 6-10, as best understood, are rejected under 35 U.S.C. 103(a) as being unpatentable over Watanabe et al., U.S. Patent 5,580,420 in view of Takahashi, U.S.Patent 5,314,574.

Watanabe et al. shows the invention substantially as claimed including a semiconductor manufacturing apparatus for processing a substrate surface (see col. 1, lines 6-14), the apparatus comprising: a vacuum vessel 6 having a top plate 3, 66; a bottom plate 31 in which a substrate stage provided (see figs. 1 and 4); two cylinders 15 installed surrounding the substrate stage (see col. 10, lines 28-35, and figs. 1 and 4); a gap between the cylinders and the top vacuum vessel plate is made variable by lifting/lowering the cylinder (see col. 7, lines 20-22); the cylinders having a lifting/lowering mechanism 36 (see col. 10, lines 28-35, and figs. 1 and 4) in order to separate a space which the cylinder surrounds comprising a processing chamber 6 from the a space outside the cylinder including a transport chamber 32 for transferring the substrate and provided with a substrate conveyer mechanism 10, 101 for transferring the substrate between the processing chamber and the transport chamber through the gap (see col. 6-line 63 to col. 7-line 25); the processing chamber is provided with a processing chamber gas inlet and a gas outlet (see col. 9, lines 55-62).

Watanabe et al. does not expressly discloses that the transport chamber is provided with a gas inlet and a gas outlet, that the cylinders are provided with an O-ring.

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and that the cylinders are connected to the bottom plate through bellows. Takahashi discloses an apparatus in which the transfer chamber comprises a gas inlet for supplying nitrogen gas and a gas outlet connected to an exhaust system in order to set a vacuum atmosphere (see col. 5, lines 24-36 and fig. 8). Therefore, in view of this disclosure it would have been obvious to one having ordinary skill in the art at the time the invention was made to modify the apparatus of Watanabe et al. as to further comprise a gas inlet and a gas outlet in the transfer chamber in order to set a vacuum atmosphere.

Furthermore, Takahashi discloses the use of O-rings 21 for tightly seal the chamber and the use of bellows 22 connected to the bottom plate 23 for freely expansion and compression of the cylinders lifting/lowering mechanism (see col. 4, lines 27-53). Therefore, in view of these disclosures it would have been obvious to one having ordinary skill in the art at the time the invention was made to modify the apparatus disclosed by Watanabe et al. as to further comprise the claimed O-ring and bellows in order to optimize the apparatus by tightly sealing the chamber and by freely expanding and compressing the lifting/lowering mechanism.

With respect to the substrate stage having a substantially constant vertical position, note that the apparatus of Watanabe et al. is capable of having the substrate stage at a substantially constant vertical position for a given amount of time.

With respect to claims 3 and 8, note that the apparatus of Watanabe et al. shows a vacuum vessel 1 which can be divided, by cylinders 15, into a part including a processing chamber 6 and a part having a substrate transport mechanism 32 (see figs.

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1 and 4). Furthermore, with respect to claims 4, 6-7 and 9-10, the Watanabe et al. reference further discloses that the apparatus comprises a microwave plasma generation mechanism for generating plasma in the processing chamber, magnetic field generating means 651-653 disposed substantially on the circumference surrounding the chamber in the atmosphere outside of the vacuum vessel, and radio frequency power source 610 provided to the substrate stage (see the abstract, col. 1-line 65 to col. 2-line 10, col. 9, line 24-62, and figs. 1 and 4).

Watanabe et al. does not expressly disclose that the magnetic field generating means are permanent magnets but it would have been obvious to one of ordinary skill in the art at the time the invention was made to modify the apparatus of Watanabe et al. as to comprise permanent magnets as the magnetic field generation means because permanent magnets are known in the art to be suitable means for generating a magnetic field and therefore their use in the apparatus of Watanabe et al. would be prima facie obvious in absence of evidence of unexpected results.

Claims 5 and 11 are rejected under 35 U.S.C. 103(a) as being unpatentable over Watanabe et al., U.S. Patent 5,580,420 in view of Takahashi, U.S.Patent 5,314,574. as applied to claims 1-4 and 6-10 above, and further in view of Masahiro et al., JP 10-177994.

Watanabe et al. and Takahashi do not expressly disclose that the plasma generation mechanism radiates microwave through a slot antenna. Masahiro et al. discloses a plasma treating device utilizing a microwave plasma generating device

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comprising a slot antenna 202 to perform uniform plasma treatment (see abstract). Therefore, in view of this disclosure, it would have been obvious to one having ordinary skill in the art at the time the invention was made to modify the apparatus of Watanabe et al. as to comprise a microwave plasma generation mechanism which comprises a slot antenna in order to optimize the apparatus by performing uniform plasma treatments with high reproducibility since the microwave can be radiated stably.

Response to Arguments

Applicant's arguments filed 10-7-02 and 1-6-03 have been fully considered but are not deemed persuasive. Applicant argues that the newly added claim limitation "... substrate stage having a substantially constant vertical position..." renders the claims of record allowable. However, it is clear that the apparatus of Watanabe et al. is capable of having the substrate stage at a substantially constant vertical position for a given amount of time. Furthermore, concerning the fact that the instant invention is allowable because it does not require lifting/lowering of the wafer, In response to applicant's argument that the references fail to show certain features of applicant's invention, it is noted that the features upon which applicant relies (i.e., an apparatus which does not require lifting/lowering of the wafer) are not recited in the rejected claim(s). Although the claims are interpreted in light of the specification, limitations from the specification are not read into the claims. See *In re Van Geuns*, 988 F.2d 1181, 26 USPQ2d 1057 (Fed. Cir. 1993).

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Conclusion

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THIS ACTION IS MADE FINAL. Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Luz L. Alejandro whose telephone number is 703-305-4545. The examiner can normally be reached on Monday to Thursday from 7:30 to 6:00.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Gregory L. Mills can be reached on 703-308-1633. The fax phone numbers for the organization where this application or proceeding is assigned are 703-872-9310 for regular communications and 703-872-9311 for After Final communications.

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Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is 703-308-0661.

Luz L. Alejandro Primary Examiner Art Unit 1763

April 21, 2003